



Atmospheric flame vapor deposition of WO₃ thin films for hydrogen detection with enhanced sensing characteristics

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ABSTRACT

Nowadays, with the increasing demand for hydrogen, sensors that can detect low concentrations of this gas are essential for its safe use. In this paper, Pd/WO₃ film hydrogen sensors are developed using a solid-feed flame vapor deposition (SF-FVD), as an atmospheric, economical, and fast film fabrication method. The crystal structure and morphology of the samples were characterized by different means. The performance of the obtained sensors was investigated for different hydrogen concentrations (1–2500 ppm) and at different operating temperatures (100–250 °C). We attempted to determine the optimum deposition conditions, including feed and substrate to flame nozzle distances. In most of the sensing conditions, the response and recovery times were measured in the order of 20 to 30 s. The layer with a more open morphology showed sensitivity at ppb hydrogen level, good stability, and selectivity. The response behavior of the samples was explained according to the power-law in the metal oxide semiconductor (MOS) gas sensors.

1. Introduction

In recent years, hydrogen has received a great deal of attention as a renewable, clean, high-efficiency, and high-energy source of energy. However, there are several barriers to the use of this gas, such as high explosiveness at 4–75% concentration range, high leakage, and low explosion threshold energy [1–4]. Because it is an odorless, colorless, and tasteless gas, it cannot be detected by the human senses. Therefore, sensors capable of detecting low concentrations of H₂ with reliable performance are essential in the processes from hydrogen production to usage.

It is known that many metal oxide semiconductors (MOS) exhibit a noticeable change in resistivity upon reaction with H₂, thus providing a basis for sensing of this gas [5–12]. MOS sensors are of more interest because they are low cost, reliable, have a simple operating mechanism, and are well integrate-able to microelectronic devices.

Tungsten oxide films, with several orders of magnitude changes in resistance in reaction with hydrogen, is one of the most promising candidates among the MOS thin film gas sensors [4,13,14].

Several fabrication methods have been used so far for thin film WO₃ gas sensors (Table 1). Despite the deposition technique, a thin Pd layer improves the sensing characteristics dramatically [24–28]. This improvement in the performance has led to 1 ppm limit of detection at room temperature, a wide range of concentration detection and

reducing the response and recovery time to a few seconds [13,14,26,29]. The cost-effective methods by which highly porous layers are obtained are preferred to achieve enhanced gas-surface adsorption.

Flame-based synthesis methods have been successfully employed in the mass-production of MOS nanostructures due to their capability in continuous operation at the atmospheric pressure with no need to vacuum facilities and extraordinarily high tunable temperatures and different configurations [30–35]. SF-FVD has the advantage of simple assembly and using the solid precursor in addition to gas and liquid precursors [36,37]. In the deposition of WO₃ with a solid-feed SF-FVD method, a flame oxidizes and evaporates a W metal mesh, wire or rod to produce W oxide vapor, which subsequently condenses on a surface to form films of distinct morphologies such as granular, nanowires and even nanotubes [38–41]. Fuel used in the synthesis of WO_x nanostructures is mainly a pre-mixed mixture of CH₄, O₂, Ar or N₂. According to the literature, significant reports in which the solid-feed SF-FVD method has been used to develop WO₃ hydrogen sensors have not yet been published, while this method has unique advantages [42–44]. It should be noted, however, that due to the high temperature of the flame, this method is usually limited to film deposition on refractory substrates such as alumina.

Very recently, we have used oxyhydrogen (derived from water splitting) flame to produce molybdenum oxide nanoparticles for

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Table 1
Comparison of fabricated sensors by different metal oxide sensing elements for the detection of H₂ gas with low concentration and high performances.

Sensor material	Fabrication method	Working temperature (°C)	Response	Limit of detection (ppm)	Response time (s)	Recovery time (s)
Single crystal Pt/WO ₃ [13]	Pulsed laser deposition	25–65	100 (100 ppm)	1	1	> 10
WO ₃ nanotubes with Pd catalyst [15]	Coaxial electrospinning	450	17.6 (500 ppm)	10	25	–
NiO nanostructure [16]	thermal oxidation & RF sputtering	150	119.63% (1000 ppm)	30	6	0.5
Mesoporous In ₂ O ₃ [17]	Hydrothermal & calcination	260	18 (500 ppm)	0.01	1.7	1.5
SnO ₂ nanofibers [18]	electrospinning	150	2.4 (1000 ppm)	600	21	33
Honeycombed SnO ₂ [19]	Wet chemical	340	8.4 (1 ppm)	0.05	4	10
TiO ₂ thin film [20]	Sol-gel	175	55% (10000 ppm)	100	2	464
CuO NW network [21]	Chemical solutions	300	340 (100 ppm)	–	60	2
CeO ₂ -loaded In ₂ O ₃ hollow spheres [22]	hydrothermal	160	20.56 (50 ppm)	0.01	1	9
Pt/Pd on ZnO nanorod clusters [23]	Template assisted method, hydrothermal & PLD	100	2.5 (10000 ppm)	0.2	5	76
Pd/WO ₃ nanostructured layer (this work)	SF-FVD	150	116.1 (12 ppb)	< 75 ppb	4	8

hydrogen sensing [45]. It has been found that this method works well on Mo and W metals. So in this article, we attempt to deposit tungsten oxide films on alumina and use them for hydrogen sensing. Probably one advantage of the technique presented in this paper is the simplicity of the deposition setup compared to similar flame-based methods such as spray pyrolysis [33,46]. Another significant contribution of the article is the high sensitivity of the obtained Pd/WO₃ layers to hydrogen gas at the ppb level. The role of the SF-FVD parameters is studied to fabricate hydrogen gas sensors. Investigations have promising results in comparison with other hydrogen gas sensors listed in Table 1. Results suggest that besides sustaining the optimum properties of the sensor, the solid-feed SF-FVD method can be used for mass production with low-cost, fast process and without requiring sophisticated vacuum facilities.

2. Experimental

2.1. Design and fabrication of SF-FVD

In this research, a homemade oxyhydrogen generator was designed and used as a flame source for the production and deposition of tungsten oxide vapor. This instrument uses DI water to produce steam of H₂/O₂ (2:1 ratio) with an 80 sccm flow rate. For the project purpose, the naked-eye visible length of the flame was adjusted about 5 cm. The resulting oxy-hydrogen flame has a bright color and sharp tip.

2.2. WO₃ and Pd layer deposition

Alumina sheets, with dimensions of 10 × 10 mm² selected as substrate. Before the WO₃ deposition, a pair of gold Inter-Digital Electrodes (IDEs) has deposited on its surface by the magnetron DC sputtering by a shadow mask in which the distance between each collecting electrodes was 200 μm. The deposition of WO₃ films was performed in a one-step process. To do this, we put a W metallic rod (purity = 99.6% and $\phi = 2.4$ mm), and Al₂O₃ substrates were at a distance of d_r and d_s, respectively, from the nozzle tip (Fig. 1(a) and Table 2). The flame was oxidizing and evaporating the W rod surface during the deposition process. The oxide species propagate across the flame to form a film on the substrates (Fig. 1(b)). Only a 2 min total deposition time was sufficient to achieve hundreds of nanometer thicknesses, indicating the process is fast comparing with traditional deposition methods. A schematic illustration for the WO₃ sensor layer on IDE coated substrate is depicted in Fig. 1(c). A thin Pd layer (~4 nm) as an H₂ catalyst was deposited on the WO₃ films by DC magnetron sputtering system working at 100 mA and 400 V (40 W power) for 3 s. The deposition pressure was set to 6 × 10^{−5} Torr during the Pd deposition process.

2.3. Material characterization

The crystal structure of the deposited layers characterized by X-ray diffraction apparatus (Asenware AW-XDM300) at 2 θ range of 10–80° in Grazing mode with incident radiation angel of 0.8°. The surface morphology and elemental analysis of tungsten oxide layers carried out by FEI QUANTA 450 FESEM. The gas sensing test was performed under static injection of predefined concentrations of H₂ gas in a homemade test chamber, with 3 min exposure time, under different temperatures (100, 150, 200 & 250°C). The desired concentrations were obtained by diluting the initial 0.5% hydrogen gas using a series of mass flow controllers. The used dilution gas was Argon, and background gas for the recovery process was ambient air. In all the tests, the relative humidity (RH) was about 30%. A circuit, as depicted in Fig. 1(d), was used to measure the electrical resistance of the sensors. It was designed for the measurement of high resistances. Resistant was recorded by an IVIUMSTAT potentiometer apparatus at current ChronoAmperometry mode with 2 V applied bias.

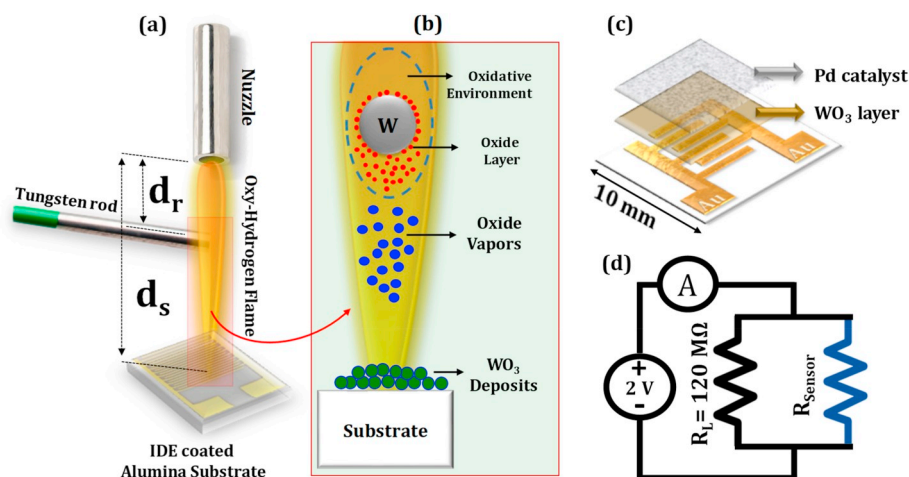


Fig. 1. Fabrication procedure of WO_3 films by SF-FVD method, (a) schematic presentation of synthesis parameters, (b) synthesis and deposition process of the tungsten oxide layer, (c) schematic illustration of IDE coated substrate and deposited WO_3 layer and (d) used circuit for the resistance measurements.

Table 2

Flame vapor deposition parameters for the fabrication of $\text{WO}_3/\text{Al}_2\text{O}_3$ films.

Sample name	S_1	S_2	S_3
d_r : rod-nozzle distance (mm)	10	15	15
d_s : substrate-nozzle distance (mm)	25	20	30

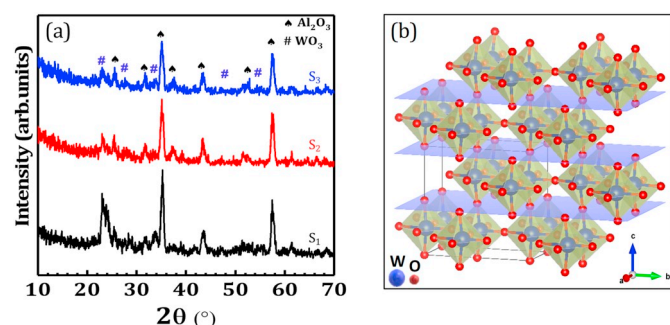


Fig. 2. (a) GIXRD patterns of $\text{WO}_3/\text{Al}_2\text{O}_3$ films deposited by the SF-FVD method at different conditions (see Fig. 1 and Table 2), (b) Schematic illustration of the orthorhombic WO_3 structure.

2.4. Gas sensing

The sensor response for reducing gas, R , is defined as

$$R = \frac{R_{\text{Air}} - R_{\text{Gas}}}{R_{\text{Gas}}} \quad (1)$$

where R_{Air} is the base resistance of the sensor in air, and R_{Gas} is the resistance measured in the presence of reducing gas. Response time is defined as the time required for the sensor resistance to drop by 90% of the total resistance during a reducing gas exposure, and recovery time is the time needed for the resistance change to recover by 90% during the baseline recovery process [14]. The response of the sensors was studied under different concentrations of 1, 3, 6, 12, 25, 50, 125, 250, 500 & 2500 ppm. For selectivity investigations, analyte gases were dynamically injected to the test chamber by a flow rate of 20 sccm for 60 s.

3. Results and discussions

3.1. XRD

The crystalline structure of the samples obtained from the SF-FVD

method was studied using GIXRD (Fig. 2(a)). The sharp peaks observed in the patterns are related to the Al_2O_3 substrate. Other peaks confirm the formation of tungsten oxide orthorhombic structure (Card number: 00-020-1324 JCPDS) for all the SF-FVD conditions. Orthorhombic tungsten oxide is reported to have better stability in interaction with hydrogen than its other structures [47]. This structure is schematically shown in part (b), in which the corner-sharing WO_6 octahedral are deformed and tilted to form parallel plates along the c axis.

3.2. FESEM

Fig. 3 shows the FESEM images of the WO_3 samples. The bottom panel also shows a typical EDS elemental map of Pd/WO_3 layers, indicating the presence of W, O, and Pd elements. In all the images, the alumina substrates are clearly visible, covered with a nanostructured WO_3 layer. Sample S_1 , with a shorter rod-nozzle distance, is much thicker (~600 nm) than the other two samples (~120 and 110 nm).

Besides, there is a significant difference in the microstructure of sample S_1 compared to the two other samples, which consists of flower-like WO_3 clusters that can provide a more porous body for hydrogen adsorption. The individual nanoparticles in the WO_3 clusters, shown on a typical TEM image, are about 100 nm in size. The surfaces of samples S_2 and S_3 have larger grains, which appear to be more tightly clamped together. Therefore, in our SF-FVD process, a short d_r distance leads to a porous flower-like morphology. This result suggests that WO_3 particles nucleate and grow homogeneously before reaching the substrate. Our FESEM analysis suggests that d_r has a vital role in controlling the thickness and porosity of layers.

Moreover, when d_r remains constant, and the relative position of substrate changes, the thickness remains unaffected. It should also be noted that all the obtained films showed high adhesion to the substrate. Indeed, we have made many samples at distances closer to the nozzle that, despite their excellent porosity, suffer from sufficient adhesion, which showed high electrical resistance and excluded from this study. Therefore, the layer conditions of the reported samples are optimal for gas sensing applications.

3.3. Gas sensing characteristics

To increase the sensitivity to hydrogen gas, we deposited a thin Pd layer on the SF-FVD $\text{WO}_3/\text{Al}_2\text{O}_3$ samples. Then, sensing characteristics were explored by the time variation of the electrical resistance on the gas introduction (Fig. 4). The n -type nature of WO_3 is responsible for the electrical resistance decreased in the presence of hydrogen gas and increased in the presence of air. The sensing response, R , was defined in

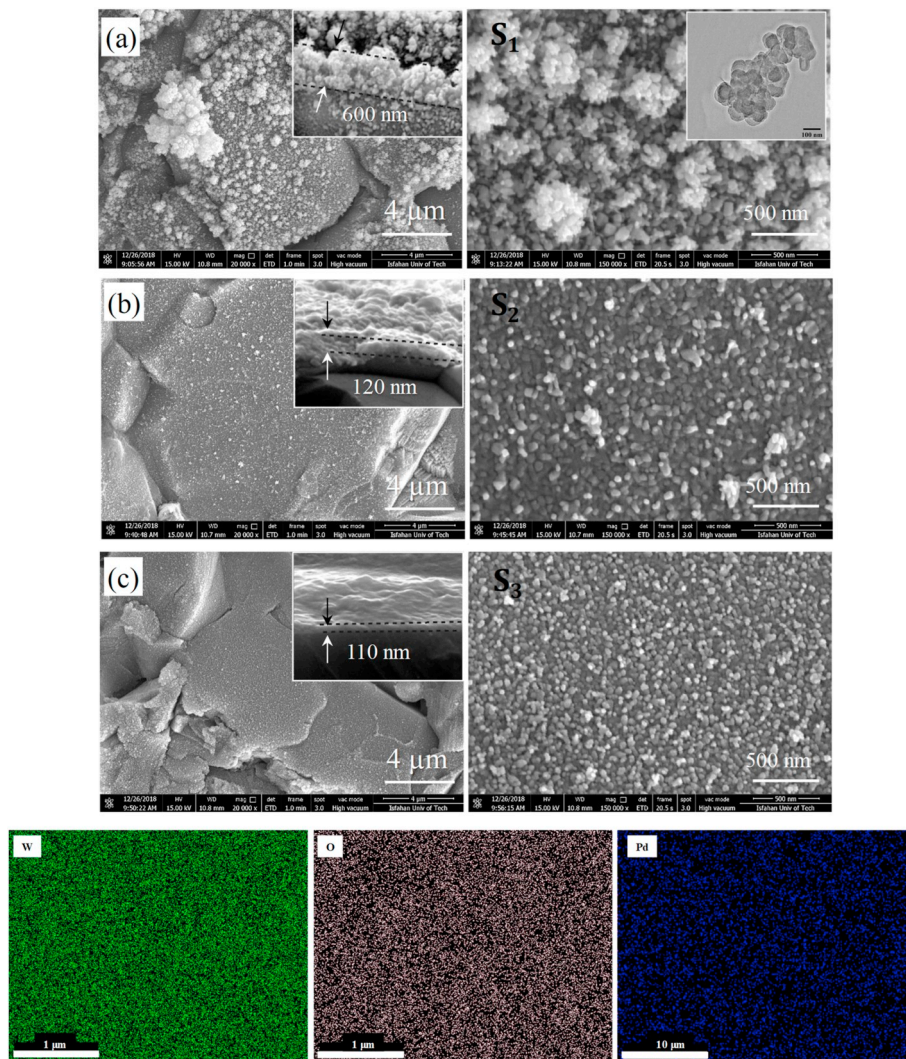


Fig. 3. Top view FESEM images of SF-FVD derived $\text{WO}_3/\text{Al}_2\text{O}_3$ films for S_1 (a), S_2 (b), and S_3 (c) at different magnifications. Insets show the cross-section images. A typical TEM image is shown for sample S_1 . The bottom panel shows a typical EDS elemental map of Pd/ WO_3 layers, indicating the presence of W, O, and Pd elements.

Eq. (1). For all the samples, S increases abruptly on hydrogen introduction but does not plateau. It drops slightly, which is less pronounced at lower gas concentrations. A thermodynamic equilibrium in the concentration of adsorbed H_2 molecules can be responsible for this drop [48]. Replacing the hydrogen with air returns S to the initial backgrounds, indicating a good reversibility behavior.

Fig. 5 shows the log-log plot of response to hydrogen gas of samples as a function of gas concentration. Each sample represents linear behavior almost at each working temperature, in agreement with the power-law behavior of the metal oxide gas sensors [49]. The sensor response was analyzed using the power law of gas sensors based on metal oxide semiconductors:

$$R = AC^\beta \quad (2)$$

where R is the sensor response, A is a pre-factor that depends on sensing component, and the working temperature, C is the gas concentrations, and β is the exponent factor that can have values of 0.5 or 1 depending on the charge state of surface oxygen atoms [50]. The obtained β values are summarized in Table 3. As can be seen, the values obtained are close to 1, suggesting that surface oxygen atoms are nearly in O^- states. For reducing gases like H_2 , it has been known that they produce water

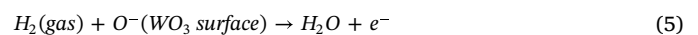
in reaction with surface oxygen. When Pd/ WO_3 grains are exposed to air, oxygen molecules existing in air atmosphere, chemisorb and get contact with the Pd clusters formed on WO_3 grains, and catalytically dissociated to form O atoms [51]:



The newly formed oxygen atoms can spillover from Pd catalyst to WO_3 surface. They trap free electrons from the conduction band of WO_3 semiconductor due to their high electron affinity and form O^- ions and remain on the surface



This capturing leads to the development of a depletion layer on the surface and increases the potential barrier height between grains, followed by dropping the concentration of electrons and increasing the resistance and provides the baseline resistance. Accordingly, one can suggest the following reaction for hydrogen sensing mechanism in SF-FVD WO_3 films:



In addition, the adsorbed H_2 molecules are dissociated into H atoms

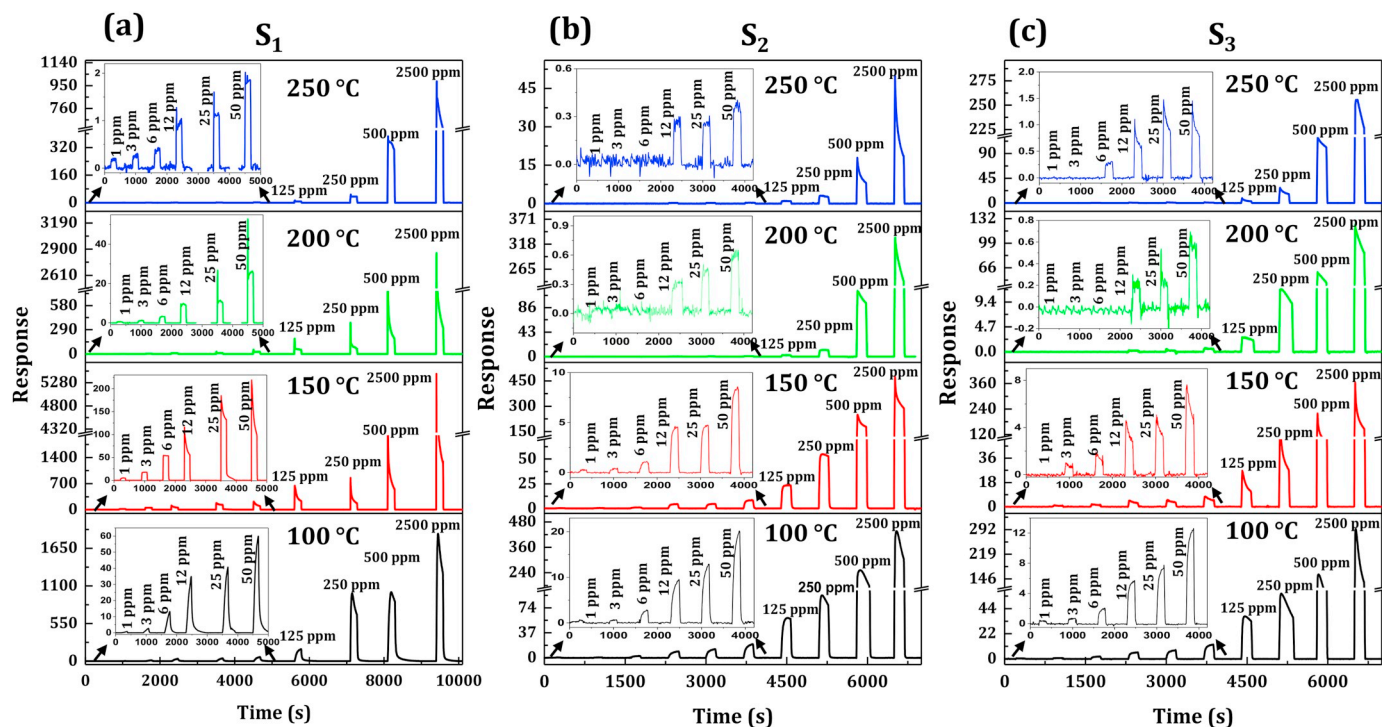


Fig. 4. Response of samples towards hydrogen gas at different concentrations and working temperatures.

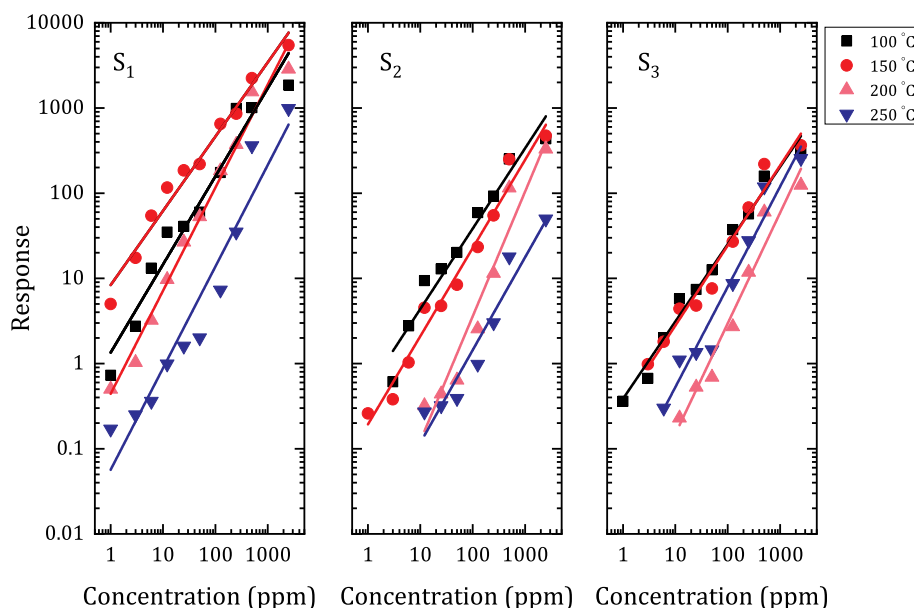


Fig. 5. Log-log plot of responses of samples as a function of hydrogen concentration for different working temperatures. (a) S_1 , (b) S_2 , and (c) S_3 .

Table 3

Exponential coefficients, β , used to fit the power law in SF-FVD WO_3 sensors.

Sample	100 °C	150 °C	200 °C	250 °C
S_1	1.0	0.87	1.20	1.20
S_2	0.94	1.03	1.40	1.08
S_3	0.91	0.94	1.30	1.17

over the Pd layer then react with the oxygen of the WO_3 layer to produce tungsten oxide bronze ((H_xWO_3)). This process also reduces W^{6+} to W^{5+} . As a result, oxygen vacancies release electron to the conduction band, leading to a decrease in the electrical resistance of the oxide layer

[4,51–54]. It can be seen that the samples sensing response is better at temperatures of 100 and 150 °C. Particularly in sample S_1 , the response is much higher at 100 °C than other existing data. Also, a decrease in the response value at higher temperatures, 200 and 250 °C, can be the result of an increase in the rate of gas desorption [4,51,55].

Fig. 6 shows the response and recovery times obtained from the dynamic response curves. Firstly, with increasing gas concentration, the response times reduce, and secondly, except at 100 °C, the response time is < 50 s at the other temperatures. The recovery times are also near to 25 s at temperatures higher than 100 °C. Therefore, in terms of detection speed, the obtained SF-FVD WO_3 hydrogen sensors are sufficiently fast. In the case of the sample S_1 , for which the rod-nozzle distance d_r is the smallest, the more open morphology of the WO_3 layer

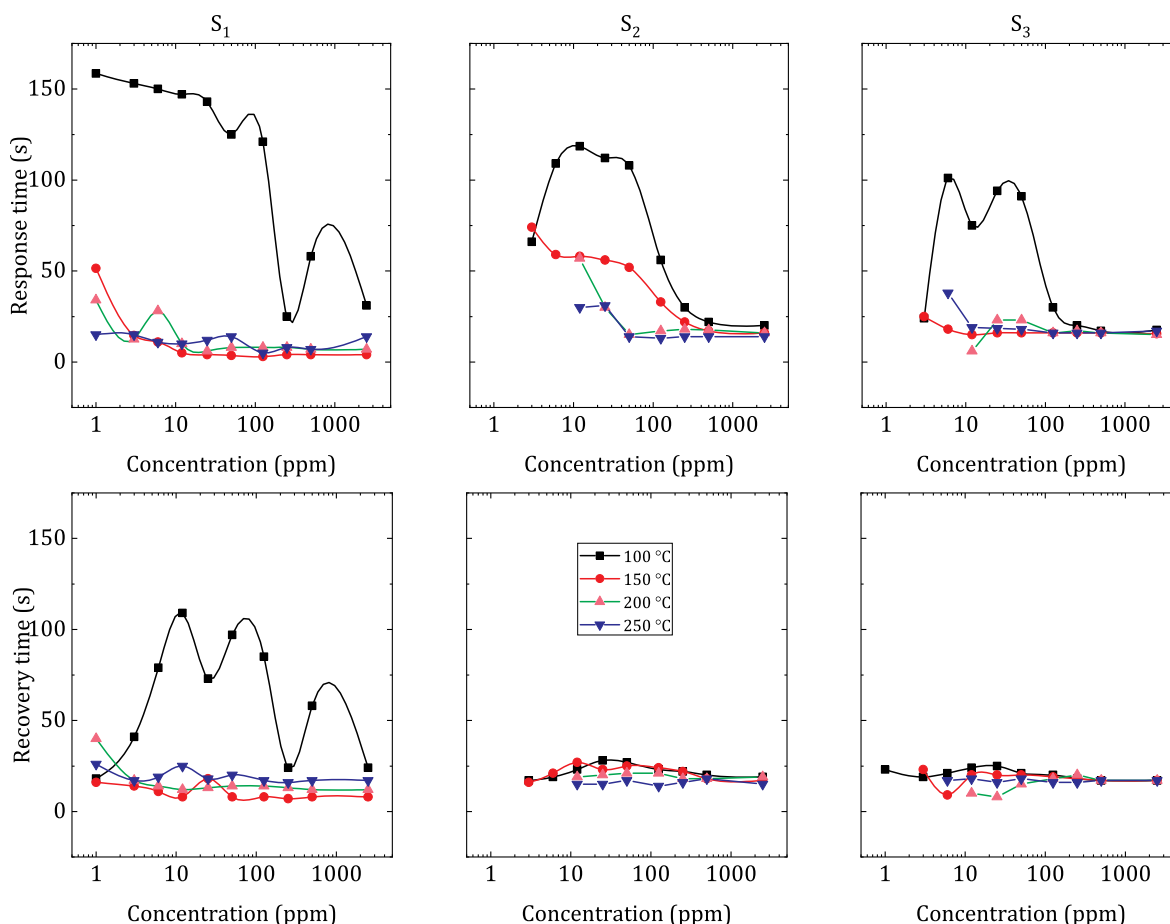


Fig. 6. Response time and recovery times of samples as a function of hydrogen concentration for different working temperatures.

(Fig. 2) can increase the gas diffusion rate into the layer pores and also enhance the surface adsorption. Therefore, the higher response values and better response/recovery times (Fig. 6) of S_1 are attributed to the layer morphology. Also, by increasing the working temperature, the diffusion and recombination rates are balanced for ions, leading to faster saturation velocity. Perhaps what the above results give us about the SF-FVD method is that, although the W rod and substrate displacements can affect the morphology and sensing characteristics, the samples have desirable sensing characteristics in all the conditions. One can conclude, therefore, that the SF-FVD method will provide devices of minimal tolerances in sensory properties in addition to being fast, mass-produced, and cost-effective.

Since sample S_1 showed better structural and sensing properties, it was used to investigate other hydrogen sensing features, including repeatability, stability, and selectivity. Fig. 7(a) shows the response and reusability of the WO_3 films in the concentration range of 75 to 1200 ppb. This graph shows two results, including the ability to reproduce well and the ability to measure hydrogen gas, even at ppb levels. Also, in the stability test shown in part (b), our product seems to have acceptable stability over 29 successive cycles with 12 ppm hydrogen gas. Therefore, the SF-FVD method can provide films with excellent reproducibility.

Fig. 7(c, d) shows the selectivity test results for sample S_1 at 150 °C towards 125 ppm H_2 , CH_4 as reducing gases and NO_2 as an oxidative gas. It reveals a current response of about 440 nA towards hydrogen and a very weak response to CH_4 (14 nA). The current response is also negative for NO_2 because of its oxidative nature [56]. This negative response is 400 times smaller than the response to hydrogen gas. Therefore, the SF-FVD derived WO_3 based sensors are highly selective

to hydrogen gas.

The selectivity of WO_3 films toward hydrogen has been vastly investigated elsewhere. Depending on the crystalline structure, working temperature, and type of the catalyst, WO_3 exhibit selectivity for different gases. For example, bare WO_3 with hexagonal structure has a very high selectivity for hydrogen sulfide [57]. The monoclinic structure requires high temperatures (> 300 °C) to detect gases such as volatile organic compounds (VOCs), CO, and NH_3 . Below these temperatures, there is no significant response for these gases [58–60]. At lower temperatures (< 200 °C), NO_2 is better detected. The response of other reducing gases such as H_2 is negligible compared to NO_2 [56,61–64]. However, it has been shown that when the palladium is used as a catalyst, the tungsten oxide response to H_2 increases dramatically compared to other gases such as H_2S , CH_4 , NH_3 , CO, and VOC [2,65–68].

4. Conclusion

WO_3 hydrogen gas sensors are fabricated successfully by a solid-feed SF-FVD method. This method has the advantage of setup simplicity, which is low cost and fast. Fabricated sensors have a good ability to detect hydrogen at low concentrations (ppb level). By changing the deposition parameters, an optimum condition for sensor fabrication could be suggested. The selected hydrogen sensor has good stability during cycling and selectivity towards other reducing or oxidizing gases. Although SF-FVD parameters affect the gas sensing characteristics, the products are expected to have minimal tolerance in sensing of hydrogen gas, suitable for mass production of cost-effective hydrogen sensors.

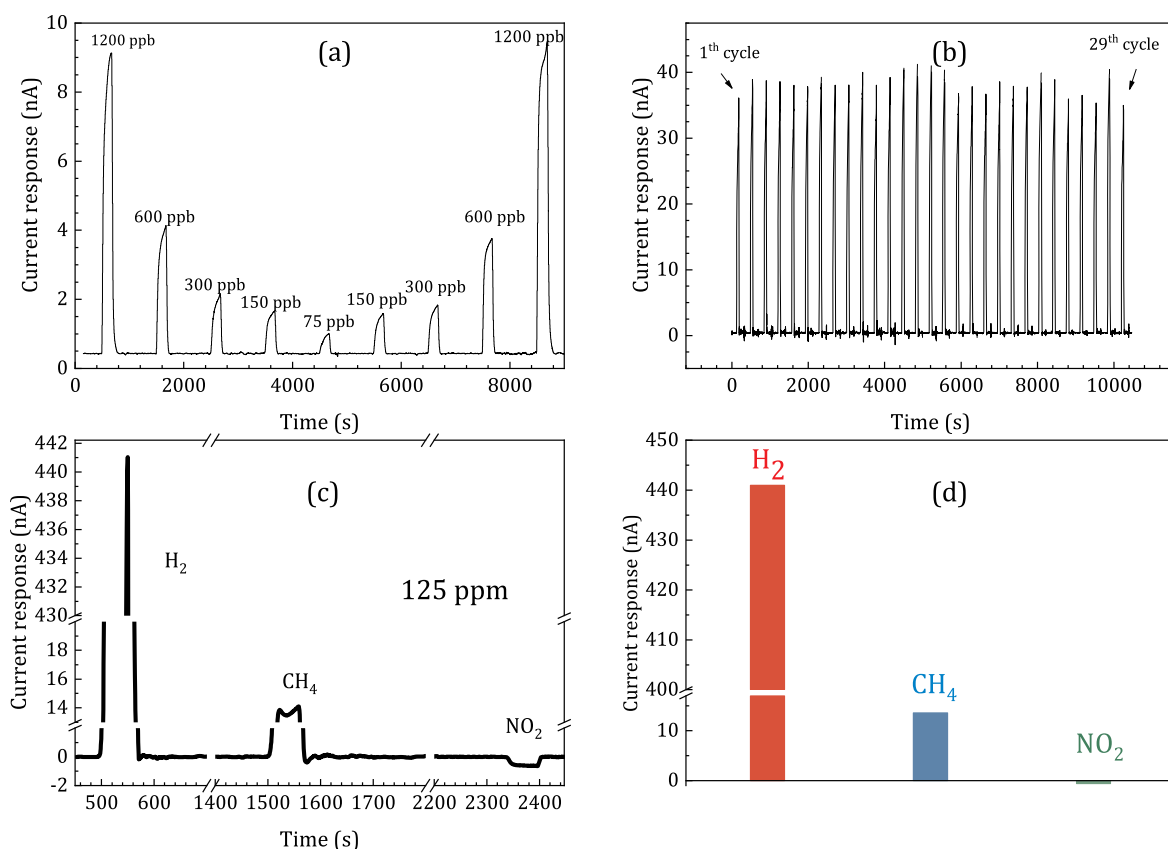


Fig. 7. (a) Reusability test of sample S_1 in the concentration range of 75–1200 ppb at 150 °C, (b) stability test of sample S_1 at 150 °C to 12 ppm hydrogen gas, (c, d) selectivity test for sample S_1 at 150 °C during exposure of deferent reducing and oxidizing gases.

Declaration of competing interest

None.

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